

2. Entrinsic Semi Conductor: Impurity Semi Conductors, in which the Charge Carriers are produced by doping of the impurity atoms into intrinsic (or) pure semiconductors. Entrinsic Semi Conductors are produced by doping of trivalent (or) Pentavalent impurity atoms into intrinsic semiconductors.

2) Difference between Intrinsic and Entrinsic Semi.

Conductor.

Interinsic Semiconductor Entrinsic Semi Conductor.

(i) Pure Semiconductor

Doped with impurity is called Entrinsic

(11) The Change Carriers are Produced only due to thermal agitation.

Charge Carriers over Produced due to impurities and to produce thermal agitation.

(iii) low electrical Conductivity

high electrical Conductivity

civ) low operating Temp.

high operating temp

(V) At T=ok, fermi level enactly lies between Ec and Ev

At TEOK, Fermilevel astechoser to Conduction bound in n-type, Closer to Valence band in p-type

(hi) Ext - Si be and Ge

Ex! - Ph and Ar



3) Difference between n-type and P-type semi

(1) Doping an intrinsic Semi Conductor With Pentavalent impurity.

(ii) es are majority Carriers holes are majority Car and holes are minority carriers and e are minority Car (111) Donor energy level closer Acceptor energy level to Conduction band.

These semi conductors can semi conductors can con easily donate an e from doner energy level to the Conduction band.

Add in trivalent impu

Valance bond (iv) Whon Temp is increased, When Temp is increased accept on e from Whiler to acceptor energy level

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Impurity added, they are classified. (1) n-type Semi Conductor!-Conduction Doping an intrinsic Semiconductor With the pentablent (five es Ed. donor in Valence bound) Ex! - Phosphorous, arsenic, Valence Born antimony * es are majority charge Carriers 11- Eype * holes are mainority charge carriers. The energy level of the doneted es are Called clonor energy level (Fd). (ii) P-type SemiConductor: - Conduction Doping an intrinsic Semiconductor With the Erivalent (3 es in Valence band). Ea Ex: Boron, Indium etc. * holes are majority charge Carriers. Valence Band * e are minority charge carriers. The energy level of the accept # e's are called Accepted energy level (FA).



2.1 (a) Fermi Energy level

At ok, Ex will lie exactly between Ec and Ed,
but even at low temp. Some electrons may go from
Ed to Ec. Let us assume that Ee-Ex>4kT. The
density of ein Conduction band,





$$2E_{f} - (E_{d} + E_{c}) = kT \log \frac{Nd}{2} \frac{Nd}{2[2\pi m_{e}^{2}kT]^{3/2}}$$

$$E_{f} = \frac{E_{d} + E_{c}}{2} + \frac{kT}{2} \log \frac{Nd}{2[2\pi m_{e}^{2}kT]^{3/2}}$$

$$At T = 0k,$$

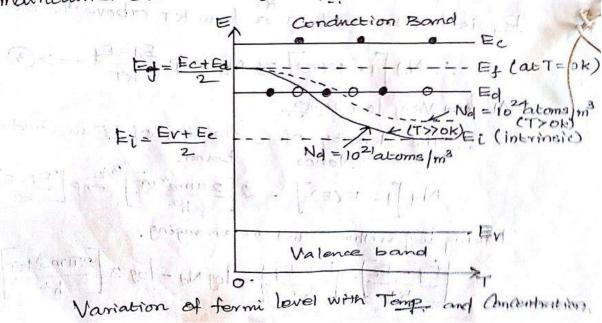
$$E_{f} = \frac{E_{d} + E_{c}}{2} \rightarrow 6$$

Fermi level lies enactly halfway between donor level and bottom of Conduction bound at T=0k.

As the temp. Increases fermi level drops.

The temp is Irradually increase from a low Temp the Contribution of es to the Conduction board from the Valence band increase and at very high Temp (Be=500).

The temp is increase, the formi level shifts bowned the intrinsic fermi level, But by increasing donor Concentration, the entrinsic behaviour may be maintained even at high Temp





in equ (1) and sub the Value of Efform equ (6). $n = 2 \sqrt{\frac{2\pi me^* kT}{h^2}} \sqrt{\frac{3}{2}} \frac{Ed_1 E_2}{2kT} \sqrt{\frac{2\pi me^* kT}{2}}$ n = and 1/2 211 me* KT 3/4 PAP Ed-Ec. The density of e (n) in Conduction bound is Proportional to the Square root of donor Concernation((e) Electrical Conductivity: The electrical Conductivity (0) in Semi Conductor, = ne (Me+Mh) -> @ For n-type Semiconductor, the acceptor aire almos zero. Therefore the mobility of charge Corriers, holes is zero. $(\mu_h = 0)$.

holes is zero. $(\mu_h = 0)$. $\sigma = ne (Me)$ $\sigma = ne (Me)$ $enp = \frac{Ed - Ec}{2kT} e(\mu_e) \rightarrow 0$